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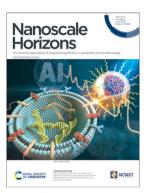
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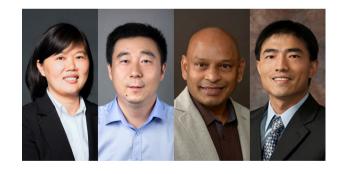
See Muhammad Zubair. Muhammad Qasim Mehmood, Yehia Massoud, Junsuk Rho et al., pp. 759-766. Image reproduced by permission of Prof. Dr Yehia Massoud from Nanoscale Horiz., 2023, 8, 759.

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Introduction to new horizons in materials for energy conversion, optics and electronics

Jinlan Wang,* Yuanjian Zhang,* Seeram Ramakrishna* and Guihua Yu*

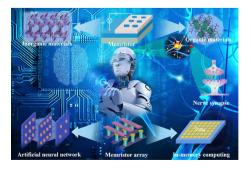


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Memristor-based neural networks: a bridge from device to artificial intelligence

Zelin Cao, Bai Sun,* Guangdong Zhou, Shuangsuo Mao, Shouhui Zhu, Jie Zhang, Chuan Ke, Yong Zhao and Jinyou Shao*



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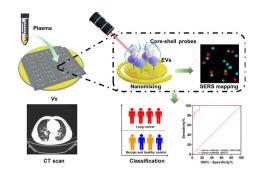


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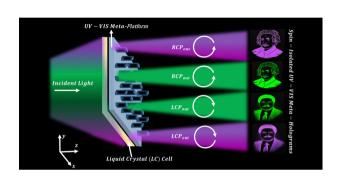
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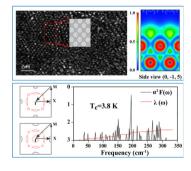
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A novel two-dimensional superconducting Ti layer: density functional theory and electron-beam irradiation

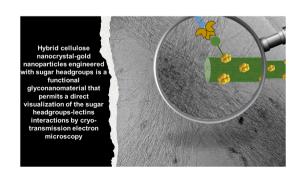
Xiao-Min Zhang, Jiawei Tang, Jing Zhang, Jin Yu, Litao Sun, Zhiqing Yang,* Ke Xia* and Weiwei Sun*



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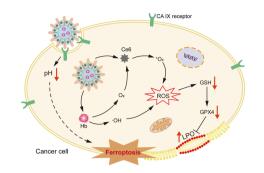
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Giacomo Biagiotti, Gianluca Toniolo, Martin Albino, Mirko Severi, Patrizia Andreozzi, Marcello Marelli, Hana Kokot, Giancarlo Tria, Annalisa Guerri, Claudio Sangregorio, Javier Rojo, Debora Berti, Marco Marradi, Stefano Cicchi, Iztok Urbančič, Yvette van Kooyk, Fabrizio Chiodo* and Barbara Richichi*



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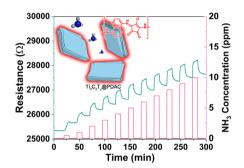
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Nian Liu, Qian Lin, Wenbao Zuo, Weibin Chen, Shan Huang, Yinshu Han, Xing-Jie Liang,* Xuan Zhu* and Shuaidong Huo*

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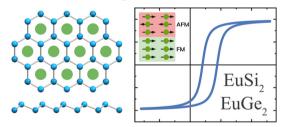


An ultra-sensitive NH₃ gas sensor enabled by an ion-in-conjugated polycroconaine/Ti₃C₂T_x core-shell composite

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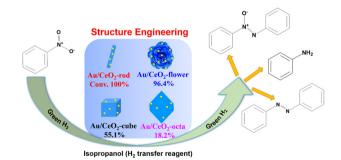
exchange bias state



Intrinsic exchange bias state in silicene and germanene materials EuX₂

Dmitry V. Averyanov, Ivan S. Sokolov, Alexander N. Taldenkov, Oleg E. Parfenov, Igor A. Karateev, Oleg A. Kondratev, Andrey M. Tokmachev and Vyacheslav G. Storchak*

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A light-operated integrated DNA walker-origami system beyond bridge burning

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